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DATE MAILED: 03/16/2005

APPLICATION NO.	FILI	NG DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/751,831	01/	05/2004	Sadanand V. Deshpande	FIS920030078US2 (16422A)	. 3568
23389	7590	03/16/2005		EXAM	INER
SCULLY S		RPHY & PRES	WOJCIECHOWICZ, EDWARD JOSEPH		
SUITE 300				ART UNIT	PAPER NUMBER
GARDEN CITY, NY 11530			2815		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/751,831	DESHPANDE ET AL.				
Office Action Summary	Examiner	Art Unit				
	Edward Wojciechowicz	2815				
The MAILING DATE of this communication appo Period for Reply	ears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period with the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be tim within the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONEI	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on	<u>.</u> .					
2a) ☐ This action is FINAL . 2b) ☑ This	action is non-final.	٠				
3) Since this application is in condition for allowan	ce except for formal matters, pro	secution as to the merits is				
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.				
Disposition of Claims						
4) Claim(s) 15-20 is/are pending in the application						
4a) Of the above claim(s) is/are withdraw	n from consideration.					
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>15-20</u> is/are rejected.						
7) Claim(s) is/are objected to.		·				
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9)☐ The specification is objected to by the Examiner	•					
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.						
Applicant may not request that any objection to the o						
Replacement drawing sheet(s) including the correcti	• • • • • • • • • • • • • • • • • • • •					
11) ☐ The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.				
Priority under 35 U.S.C. § 119	·					
12) ☐ Acknowledgment is made of a claim for foreign a) ☐ All b) ☐ Some * c) ☐ None of:	priority under 35 U.S.C. § 119(a))-(d) or (f).				
1. Certified copies of the priority documents	have been received.					
2. Certified copies of the priority documents						
3. Copies of the certified copies of the priori	•	ed in this National Stage				
application from the International Bureau * See the attached detailed Office action for a list of		and .				
See the attached detailed Office action for a list t	or the certified copies flot receive	ou.				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	Paper No(s)/Mail Da	ate Patent Application (PTO-152)				
Paper No(s)/Mail Date <u>11-17-04</u> .	6) Other:	, , , , , , , , , , , , , , , , , , ,				

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 15, 16, 18-20 are rejected under 35 U.S.C. 102(b) as being anticipated by Mandelman et al. The features of the claimed invention are taught by Mandelman which shows an FET with a trench isolation region, such as (31) in Fig. 3, and having a nitride liner (16) located on the sidewalls and bottom wall of the trench. Mandelman also teaches the formation of both NFET and PFET devices at the same time, and specifically mentions that the nitride liner should be used for the NFET devices only, while the nitride liner may be removed from the areas of the chip where the PFET devices are formed (col. 3, 1.65-67).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claim 17 is rejected under 35 U.S.C. 103(a) as being unpatentable over Mandelman in view of Divakaruni et al. While Mandelman teaches the basic advantages of using a nitride liner, he does not specifically teach the use of very thin nitride layers between 0.1 to about 2.0 nm. However, Divakaruni, which also forms nitride lined trenches for use in semiconductor devices, teaches that such nitride layers may advantageously be on the order of 1 nm thick. Such a nitride layer would meet the dimension range recited in claim 17. One skilled in the art would be motivated to combine these references because applying a thinner nitride layer would save time and simplify the manufacture of the Mandelman device, while still achieving the desired isolation characteristics.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edward Wojciechowicz whose telephone number is (571) 272-1739. The examiner can normally be reached on Monday through Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on (571) 272-1664. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pairdirect.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (tollfree).

Edward Wojciechowicz

Primary Examiner Art Unit 2815

EW: ew